

Fe-Pt-OXIDE-BN-BASED SINTERED COMPACT FOR SPUTTERING TARGET

ABSTRACT

Provided is an Fe-Pt-oxide-BN-based sintered compact for a high-density sputtering target that can suppress generation of particles during sputtering.

The Fe-Pt-oxide-BN-based sintered compact for a sputtering target has a mass ratio of N to B (N/B) in a range of 1.30 ± 0.1 .